

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	222	(polish\$3 or cmp or planariz\$5) same (Ru or ruthenium)	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 13:00			0
2	BRS	L7	31181	ceria or cerium or "cerium oxide" or "Ce+4"	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 11:06			0
3	BRS	L13	5	1 same 7	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 10:34			0
4	BRS	L19	33276	ceria or cerium or "cerium oxide" or "Ce+4" or "ceric oxide" or ceric	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 11:07			0
5	BRS	L25	6	19 same 1	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 12:54			0
6	BRS	L37	223	(polish\$3 or cmp or planariz\$5) same (Ru or ruthenium or SrRuO3)	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 13:08			0
7	BRS	L43	112917	438/\$.cccls.	USPAT; EPO; JPO; DERWEN; T; IBM TDB	2001/06/29 13:04			0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co m m e n t s	Er r o r D e f i n i t i o n	Er r o r s
8	BRS	L49	42	37 and 43	USPAT; EPO; JPO; DERWEN T; IBM TDB	2001/06/29 13:04			0
9	BRS	L55	2	(polish\$3 or cmp or planariz\$5) same (SrRuO3)	USPAT; EPO; JPO; DERWEN T; IBM TDB	2001/06/29 13:08			0

	Type	Hits	Search Text	DBs	Time Stamp	Com men ts	Er ror De fini tion	Er ror s
1	BRS	1	polishing same (Ru or SrRuO3 or RuO3 or RuO2) same liquid	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:50			0
2	BRS	1	polishing same (Ru or SrRuO3 or RuO3 or RuO2) same liquid same(Ce(NO3)"4" or cerium or "diammonium cerium nitrate")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 12:05			0
3	BRS	110	polishing same liquid same (Ce(NO3)"4" or cerium or "diammonium cerium nitrate")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:38			0
4	BRS	6	(Ru or SrRuO3 or RuO3 or RuO2) and (polishing same liquid same (Ce(NO3)"4" or cerium or "diammonium cerium nitrate"))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 10:55			0
5	BRS	92247	(Ce(IV) or Ce("4") or (cerium near5 tetravalent) or Ce(SO4)"4" or Ce(NO3)"3"(OH)) same (polishing or cmp or liquid or solution)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:51			0
6	BRS	112917	438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:49			0
7	BRS	1062	((Ce(IV) or Ce("4") or (cerium near5 tetravalent) or Ce(SO4)"4" or Ce(NO3)"3"(OH)) same (polishing or cmp or liquid or solution)) and 438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:50			0
8	BRS	17	(Ru or SrRuO3 or RuO3 or RuO2) and (((Ce(IV) or Ce("4") or (cerium near5 tetravalent) or Ce(SO4)"4" or Ce(NO3)"3"(OH)) same (polishing or cmp or liquid or solution)) and 438/\$.ccls.)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 11:51			0
9	BRS	1	(polishing or cmp) same (Ru or SrRuO3 or RuO3 or RuO2) same liquid same(Ce(NH4)"2" or cerium or "diammonium cerium nitrate")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 12:07			0
10	BRS	4	(polishing or cmp or slurry) same (Ru or SrRuO3 or RuO3 or RuO2) same liquid same(Ce(NH4)"2" or cerium or "diammonium cerium nitrate")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 12:07			0

	Type	Hits	Search Text	DBs	Time Stamp	Co m m e n t s	Er r o r D e f i n i t i o n	Er r o r s
11	BRS	79	(polishing or cmp or slurry) same (Ru or SrRuO3 or RuO3 or RuO2) same (Ce(NH4)"2" or cerium or "diammonium cerium nitrate")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/26 12:08			0
12	BRS	2	CeO2 same (Ru or RuO2 or SrRuO3 or ruthenium) same (cmp or slurry or liquid or polish)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:09			0
13	BRS	4	(CeO2 same (Ru or RuO2 or SrRuO3 or ruthenium)) and (cmp or slurry or liquid or polish)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:33			0
14	BRS	128	CeO2 same (cmp or slurry or liquid or polish)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:33			0
15	BRS	272	CeO2 and (cmp or slurry or liquid or polish)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:34			0
16	BRS	112917	438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:34			0
17	BRS	2	438/\$.ccls. and (CeO2 same (cmp or slurry or liquid or polish))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:35			0
18	BRS	4	438/\$.ccls. and (CeO2 and (cmp or slurry or liquid or polish))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:44			0
19	BRS	455	ceria same (cmp or polishing or slurry)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:40			0
20	BRS	583	(ceria or CeO2) same (cmp or polishing or slurry)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:57			0

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21	BRS	4	(Ru or RuO2 or SrRuO3 or ruthenium) same ((ceria or CeO2) same (cmp or polishing or slurry))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:46			0
22	BRS	4	((Ru or RuO2 or SrRuO3 or ruthenium) and ((ceria or CeO2) same (cmp or polishing or slurry))) and 438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:47			0
23	BRS	81	(Ru or RuO2 or SrRuO3 or ruthenium) and ((ceria or CeO2) same (cmp or polishing or slurry))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 10:51			0
24	BRS	15343	(ceria or CeO2 or abrasive) same (cmp or polishing or slurry)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 09:49			0
25	BRS	806	((ceria or CeO2 or abrasive) same (cmp or polishing or slurry)) and 438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 08:59			0
26	BRS	10	(Ru or ruthenium) and (((ceria or CeO2 or abrasive) same (cmp or polishing or slurry)) and 438/\$.ccls.)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:09			0
27	BRS	347	(Ru or ruthenium or W or Cu) and (((ceria or CeO2 or abrasive) same (cmp or polishing or slurry)) and 438/\$.ccls.)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 09:48			0
28	BRS	711973	(Ru or ruthenium or Ti or TiN or Ta or TaN)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:09			0
29	BRS	232	(ceria or CeO2 or "cerium oxide" or abrasive) same (cmp or polishing or slurry) same (TiN or Ti or Ta or TaW)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:38			0
30	BRS	12	((Ru or RuO2 or SrRuO3 or ruthenium) near5 (Ni or Al or Fe or Cu or Zn or Ti or Cr)) same (cmp or polishing)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:28			0

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31	BRS	1800732	polishing liquid	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:40			0
32	BRS	17957	abrasive same (polishing liquid)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:40			0
33	BRS	476	(ceria or CeO2 or "cerium oxide") same (abrasive same (polishing liquid))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:42			0
34	BRS	77	cmp same ((ceria or CeO2 or "cerium oxide") same (abrasive same (polishing liquid)))	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 11:42			0
35	BRS	454	(alumina or silica or ceria or "cerium oxide" or CeO2 or Al2O3 or SiO2) same (Ru or RuO2 or SrRuO3 or ruthenium) same (cmp or slurry or liquid or polish\$3)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:13			0
36	BRS	1	((alumina or silica or ceria or "cerium oxide" or CeO2 or Al2O3 or SiO2) same (Ru or RuO2 or SrRuO3 or ruthenium) same (cmp or slurry or liquid or polish\$3)) and 438/\$.ccls.	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:12			0
37	BRS	37	(ceria or "cerium oxide" or CeO2 or Al2O3 or SiO2) same (Ru or RuO2 or SrRuO3 or ruthenium) same (cmp or slurry or liquid or polish\$3)	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/06/28 12:13			0